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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Serial No.:	10/707,388	Conf. No.:	1387
Filing Date:	12/10/2003	Art Unit:	2891
Applicant:	Divakaruni et al.	Examiner:	Fulk, Steven J.
Title:	SILICIDE RESISTOR IN BEOL LAYER OF SEMICONDUCTOR DEVICE AND METHOD	Docket No.:	FIS920030274 (IBMF-0032)

COMMISSIONER FOR PATENTS

DESTINATION FACSIMILE NUMBER: 571-273-8300

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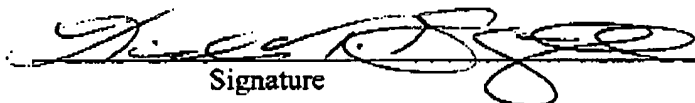
Amendment in 07 pages

in the above identified application.

CERTIFICATION OF FACSIMILE TRANSMISSION

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		Examiner:	Fulk, Steven J.

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Sir:

I. INTRODUCTORY COMMENTS:

In response to the Office Action of June 30, 2006, please amend the above-referenced patent application as follows: